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Metal Oxide Thin Films: Synthesis, Characterization and Applications

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Message from the Guest Editors

Dear colleagues,

The last two decades have seen an intensive improvement in thin film deposition methods, enabling the precise coating of surfaces at the nanoscale. Today, it is possible to coat surfaces with complex compositions and synthesize multilayers. The deposition of complex structures allows for the development of new technologies, with recent advances in deposition techniques further miniaturizing electronic devices. The development of these new technologies towards scaling down the size of the produced devices requires accurate control of the deposition process. The latter then allows tailoring thin films and nanodevices to ones desires.

This Special Issue will compile recent developments in the field of metal oxide thin film deposition. The articles presented in this Special Issue will cover various topics, ranging from but not limited to the optimization of deposition methods, thin films preparations, the functionalization of surfaces with targeted applications, nanosensors, catalysis, electronic devices, biocidal coating, and the synthesis of nanostructures via the accurate control of thin film deposition methods, among others.













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Message from the Editor-in-Chief

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